

Electronic Supplementary Information (ESI)

Al³⁺ inducing growth of α -Co(OH)₂ nanoplates as high capacity supercapacitors and water oxidation electrocatalyst

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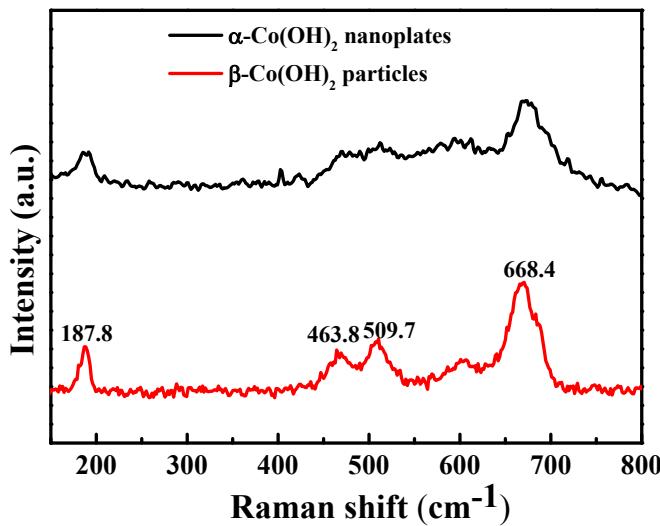


Fig. S1 Raman spectroscopy for the samples.

Figure S1 shows the Raman spectrum of the α -Co(OH)₂ nanoplates and β -Co(OH)₂ particles, which would provide additional insights into the chemical composition of the samples. All the Raman peaks at 187.8, 463.8, 509.7 and 668.4 cm⁻¹ can be assigned to the characteristic E_g(T), A_{1g}(T), A_{2u}(T) and E_g(R) modes of the hexagonal brucite-like Co(OH)₂, respectively.^[1,2] When introduced Al³⁺ ions into the reaction system, Al³⁺ ions partly substitute the position of Co²⁺ ions and form layer α -Co(OH)₂ nanoplates, the Raman modes of α -Co(OH)₂

nanoplates broaden compared with that of the $\beta\text{-Co(OH)}_2$ particles. This behavior could be attributed to attributed to vacancies, structural defects and chemical impurities.^[1,3]

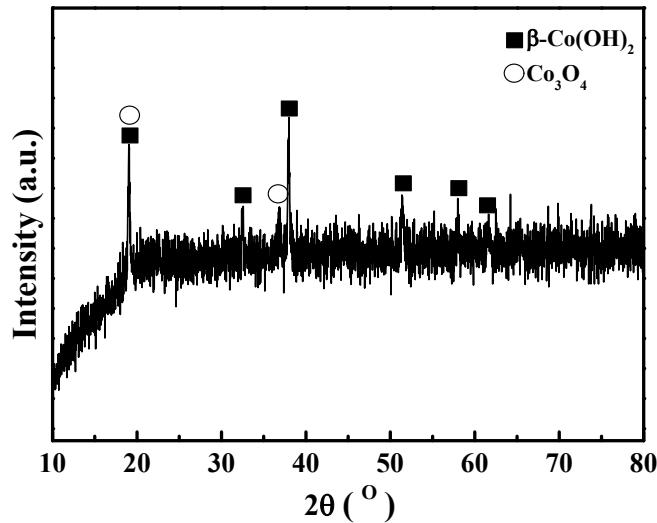


Fig. S2 XRD pattern of the sample controlled by NaCl.

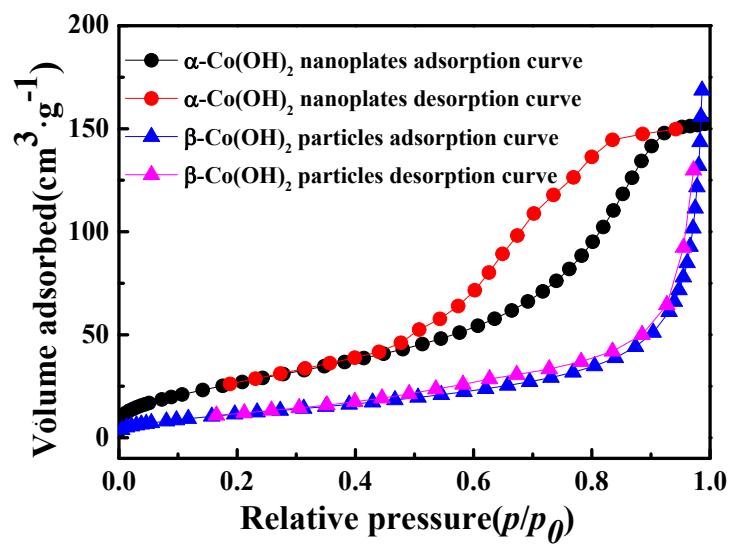


Fig. S3 Nitrogen adsorption-desorption isotherms of the samples.

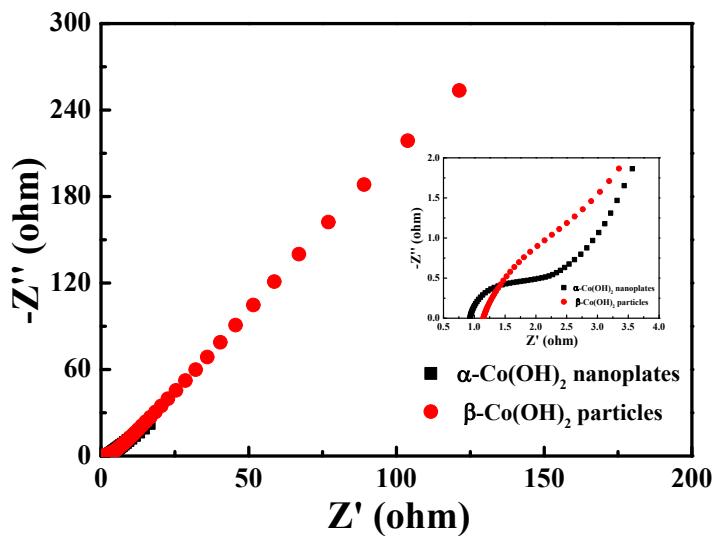


Fig. S4 Electrochemical impedance spectra of α -Co(OH)₂ nanoplates and β -Co(OH)₂ particles for supercapacitor.

Table S1. The OER activities of different samples in 1M KOH

sample	Onset potential (V vs. RHE)	η at 10 mA·cm ⁻² [mV]	Mass activity at $\eta=348$ mV (A/g)	Tafel slope [mV/dec]
α -Co(OH) ₂ nanoplates	1.51	348	28.2	151.8
β -Co(OH) ₂ particles	1.59	449	0.2	95.6

References

- 1 S. R. Shieh, T. S. Duffy, *Phys. Rev. B*, 2002, **66**, 134301-134308.
- 2 S. Gao, Y. F. Sun, F. C. Lei, L. Liang, J. W. Liu, W. T. Bi, B. C. Pan, Y. Xie, *Angew. Chem. Int. Ed.*, 2014, **53**, 12789-12793.
- 3 M.C. Bernard, R. Cortes, M. Keddam, H. Takenouti, P. Bernard, S. Senyach, *J. Power Sources*, 1996, **63**, 247-254.